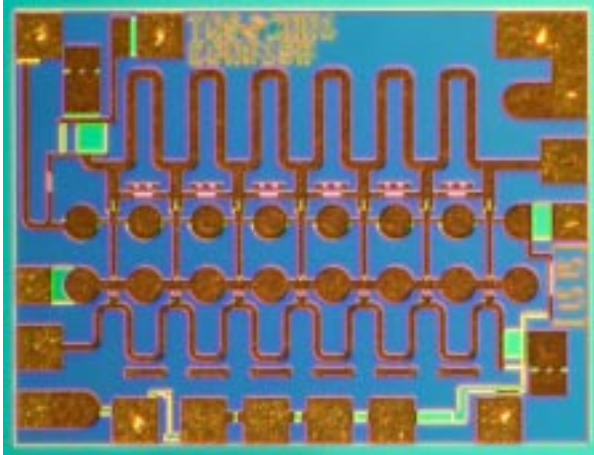


**DC - 60 GHz Low Noise Amplifier**

**TGA4811**



**Key Features**

- 60 GHz Bandwidth
- 3.0 dB noise figure
- > 15 dB small signal gain
- 13 dBm P1dB
- +/- 7 ps group delay variation
- Bias: 6V, 50 mA
- 0.15 um 3MI mHEMT Technology
- Chip Dimensions: 1.30 x 1.06 x 0.1 mm (0.051 x 0.042 x 0.004) in

**Primary Applications**

- Wideband LNA / gain block
- Test Equipment
- 40 Gb/s optical networks

**Description**

The TriQuint TGA4811 is a DC - 60 GHz low noise amplifier that typically provides 15 dB small signal gain and input and output return loss is <10dB. Normal Noise Figure is 3.0 dB from 2 - 40 GHz. P1dB is 13 dBm.

The TGA4811 is an excellent choice for Test Equipment, 40Gb/s optical network applications, and general wideband LNA and Gain Block applications.

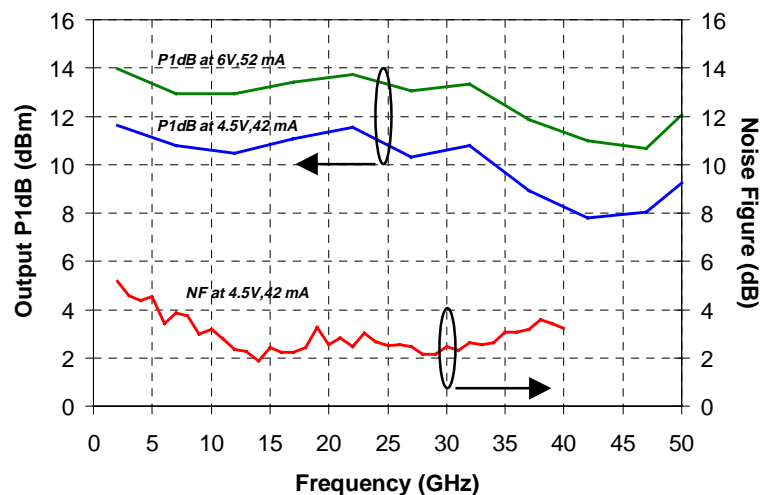
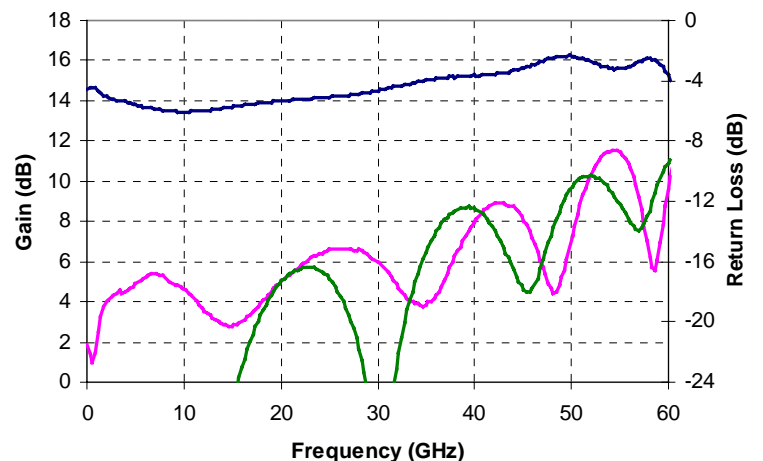
The TGA4811 is 100% RF tested to ensure performance compliance.

Lead-Free & RoHS compliant.

Samples are available.

**Measured Data**

Bias Conditions: Vd = 6 V, Id = 50 mA



*Note: This device is early in the characterization process prior to finalizing all electrical specifications. Specifications are subject to change without notice.*

**TABLE I**  
**MAXIMUM RATINGS 1/**

<b>SYMBOL</b>	<b>PARAMETER</b>	<b>VALUE</b>	<b>NOTES</b>
V <sup>+</sup>	Positive Supply Voltage	6.5 V	<u>2/</u>
V <sup>-</sup>	Negative Supply Voltage Range	-2 TO 0 V	
I <sup>+</sup>	Positive Supply Current	200m A	
I <sub>G</sub>	Gate Supply Current	10 mA	<u>3/</u>
P <sub>IN</sub>	Input Continuous Wave Power	TBD	
P <sub>D</sub>	Power Dissipation	0.69 W	<u>2/ 4/</u>
T <sub>CH</sub>	Operating Channel Temperature	110 °C	<u>5/</u>
T <sub>M</sub>	Mounting Temperature (30 Seconds)	175 °C	
T <sub>STG</sub>	Storage Temperature	-65 to 110 °C	

- 1/ These ratings represent the maximum operable values for this device.
- 2/ Combinations of resistors voltage and 3V (MAX) on mHEMT.
- 3/ Total current for the entire MMIC.
- 4/ When operated at this bias condition with a base plate temperature of 70 °C, the median life will be reduced.
- 5/ Junction operating temperature will directly affect the device median time to failure (MTTF). For maximum life, it is recommended that junction temperatures be maintained at the lowest possible levels.

**TABLE II**  
**ELECTRICAL CHARACTERISTICS**

(Ta = 25 °C, Nominal)

PARAMETER	TYPICAL	UNITS
Drain Voltage	6	V
Quiescent Current	50	mA
Small Signal Gain, S21	15	dB
Input Return Loss, S11	10	dB
Output Return Loss, S22	15	dB
Reverse Isolation, S12	-40	dB
Output Power (P1dB)	13	dBm
Power @ saturated, Psat	15	dBm
Noise figure	3.0	dB

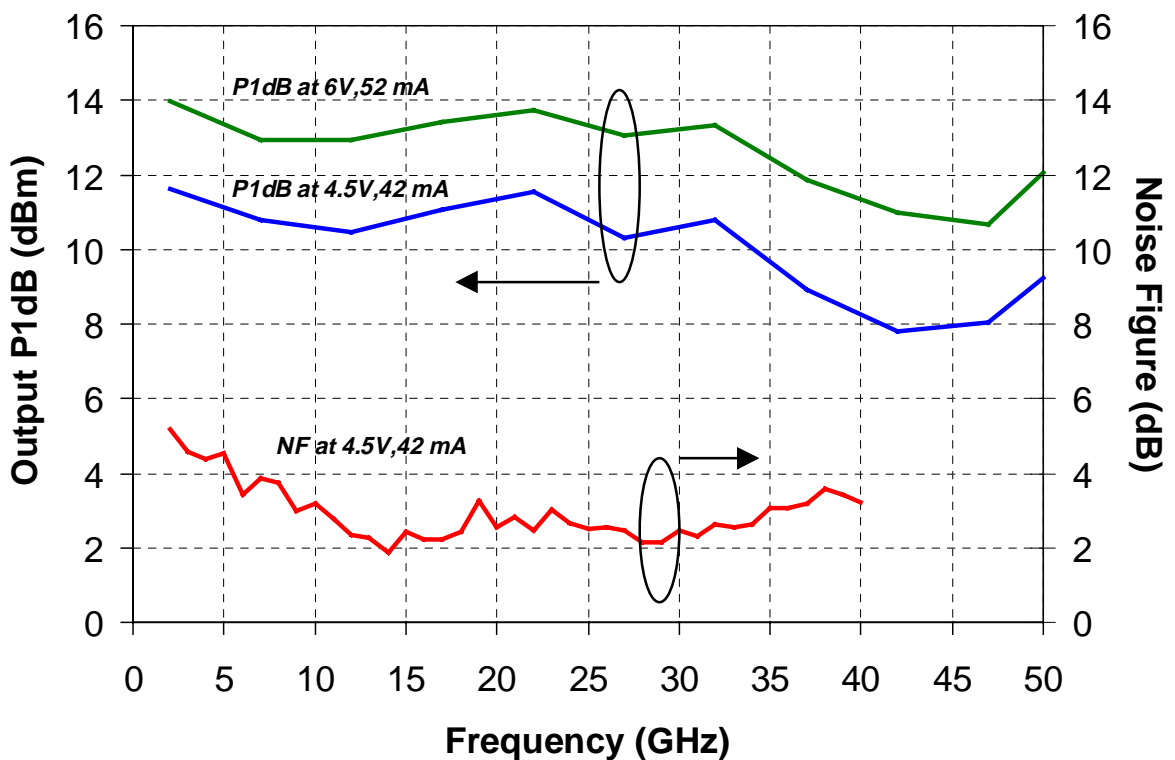
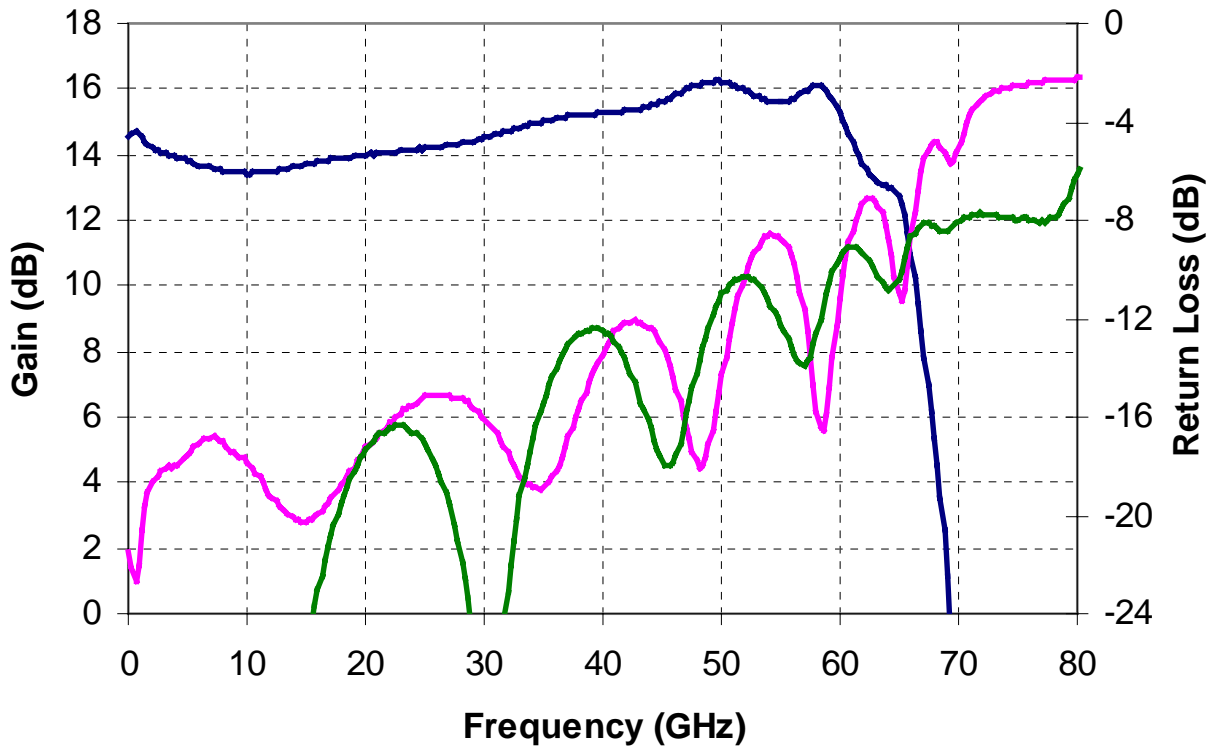
**TABLE III**  
**THERMAL INFORMATION**

Parameter	Test Conditions	T <sub>CH</sub> (°C)	R <sub>θJC</sub> (°C/W)	T <sub>M</sub> (HRS)
R <sub>θJC</sub> Thermal Resistance (channel to backside of package)	Vd = 6 V I <sub>D</sub> = 0.05 A Pdiss = 0.3 W	80	33.3	8.7E8

Note: Die backside epoxy attached to carrier at 70°C baseplate temperature.

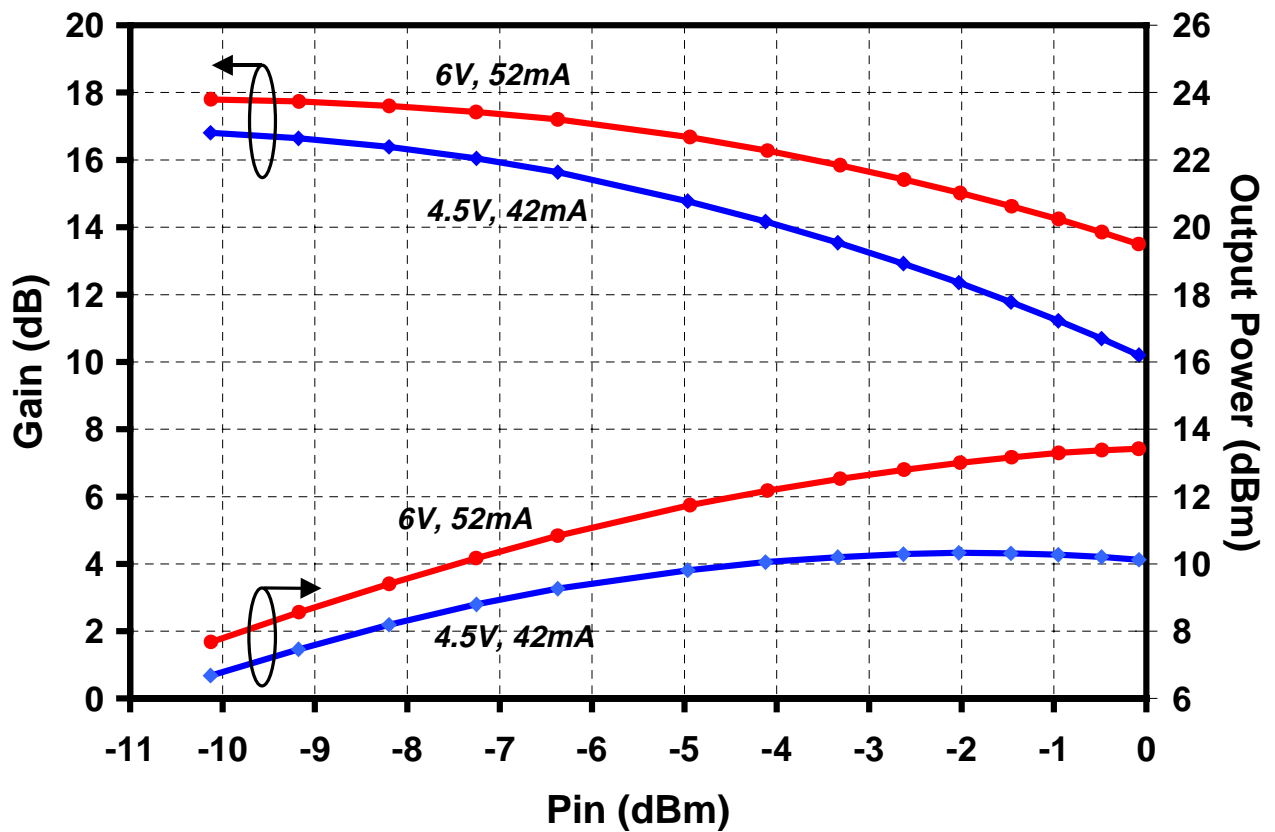
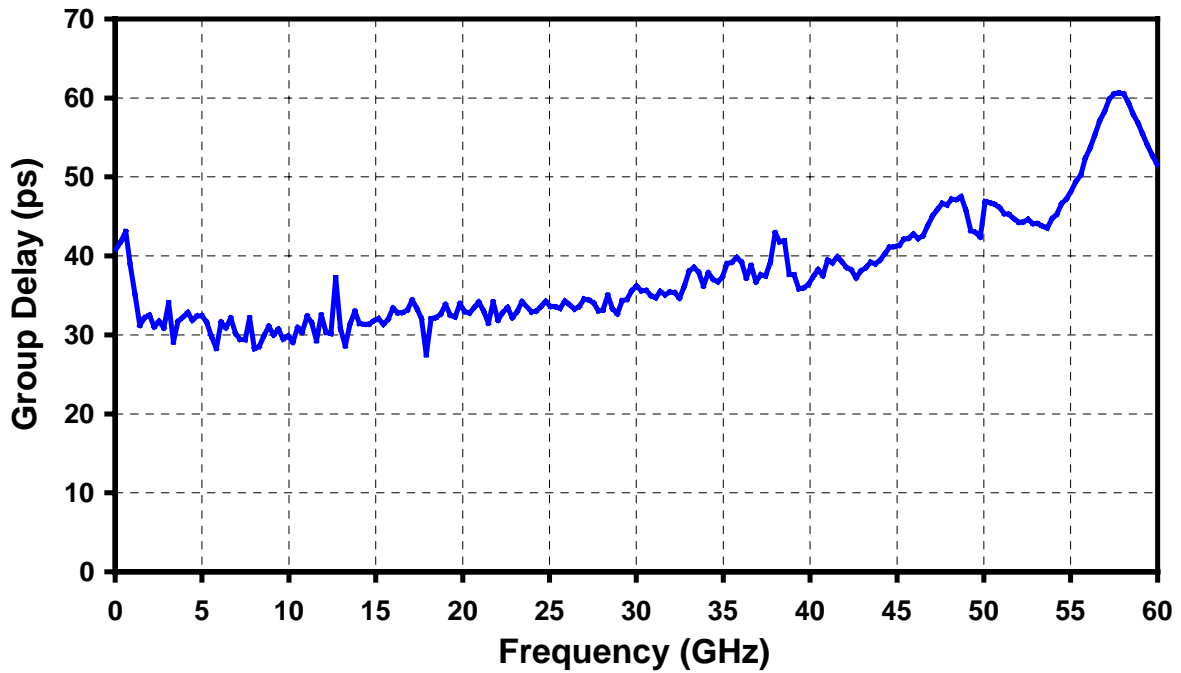
**Measured Data**

Bias Conditions:  $V_d = 6\text{ V}$ ,  $I_d = 50\text{ mA}$

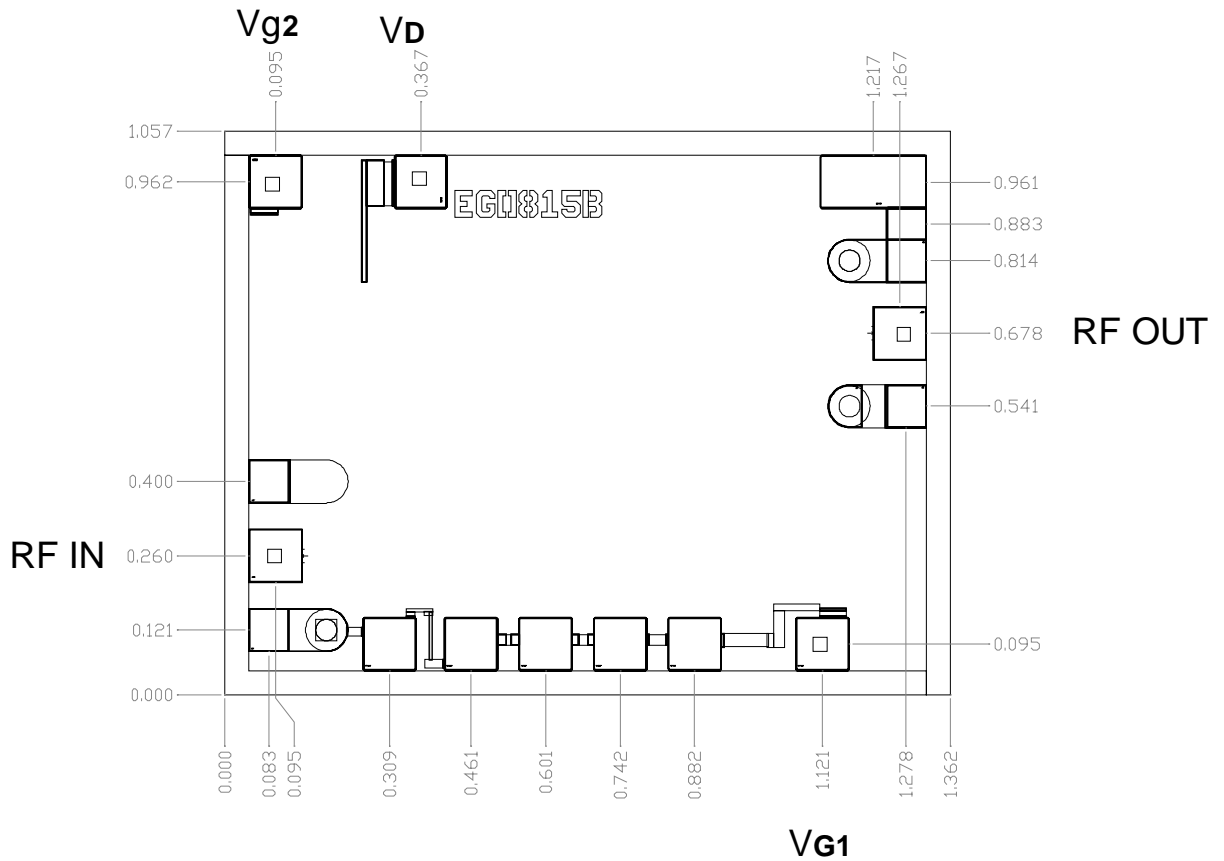


**Measured Data**

Bias Conditions:  $V_d = 6\text{ V}$ ,  $I_d = 50\text{ mA}$



**Mechanical Drawing**



Units: millimeters

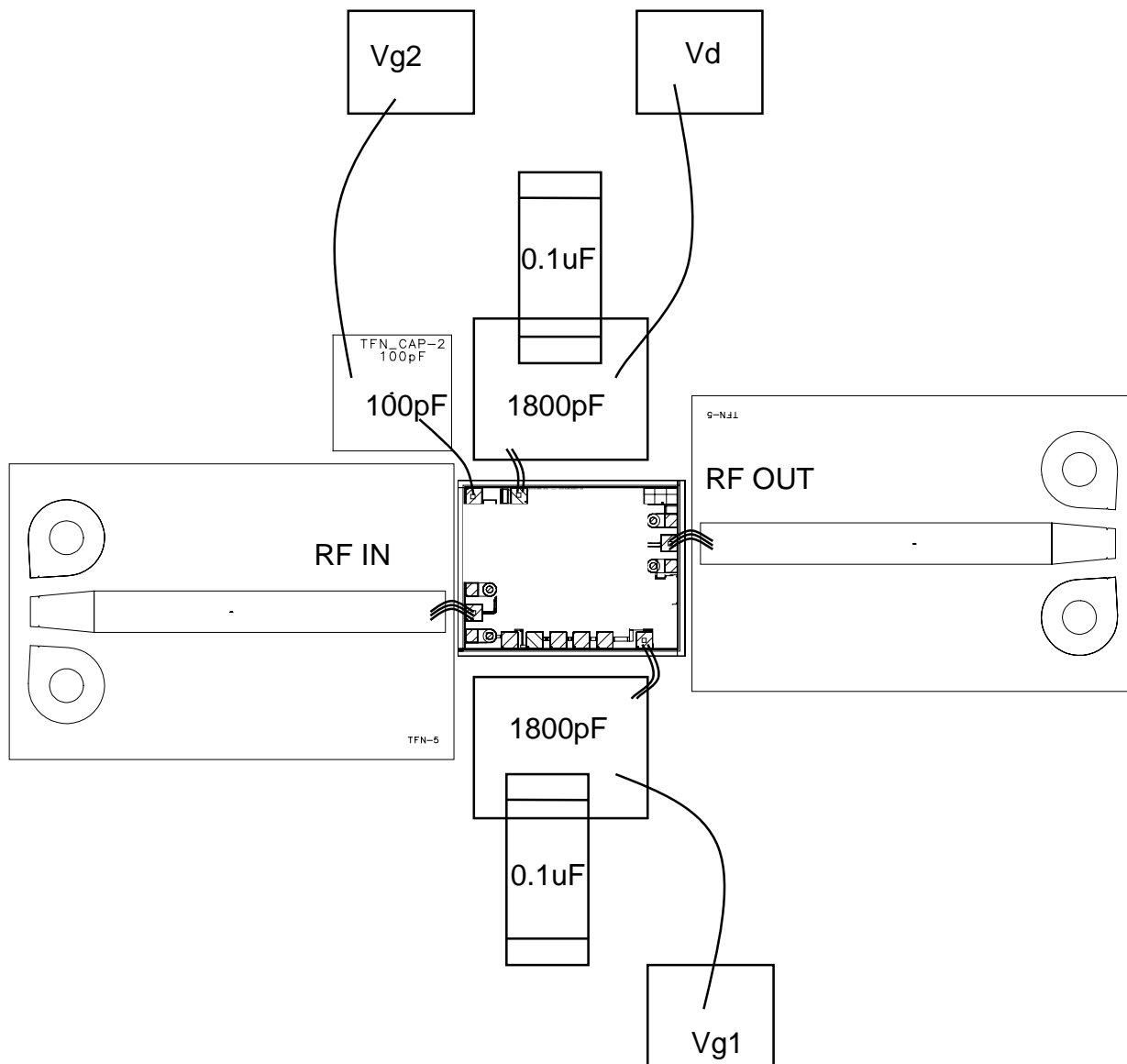
Thickness: 0.1

Chip edge to bond pad dimension are shown to center of bond pad.

Chip size tolerance: ± 0.051

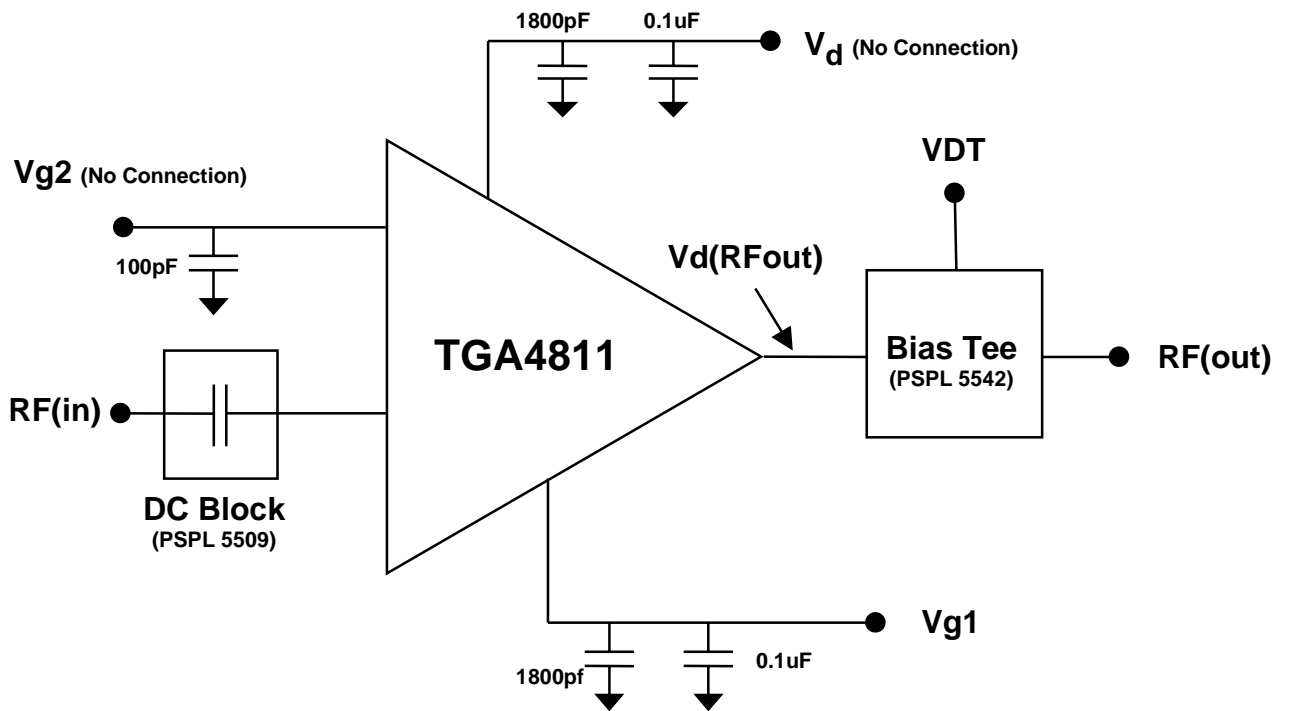
	Pad size (mm)
VD	0.10x0.10
VG1	0.10x0.10
VG2	0.10x0.10
RF IN	0.10x0.10
RF OUT	0.10x0.10

**Chip Assembly Diagram**



3 (Three) 0.7 mil chisel bond wires at RF IN and RF OUT or 1 (one) 3 mil ribbon at RF IN and RF OUT. Vg2 is optional for the circuit.

**Optional Testing Circuit Schematic**





## **Assembly Process Notes**

Reflow process assembly notes:

- Use epoxy with limited exposure to temperatures at 175°C.
- No fluxes should be utilized.
- Coefficient of thermal expansion matching is critical for long-term reliability.
- Devices must be stored in a dry nitrogen atmosphere.

Component placement and adhesive attachment assembly notes:

- Vacuum pencils and/or vacuum collets are the preferred method of pick up.
- Air bridges must be avoided during placement.
- The force impact is critical during auto placement.
- Organic attachment can be used in low-power applications.
- Curing should be done in a convection oven; proper exhaust is a safety concern.
- Microwave or radiant curing should not be used because of differential heating.
- Coefficient of thermal expansion matching is critical.

Interconnect process assembly notes:

- Thermosonic ball bonding is the preferred interconnect technique.
- Force, time, and ultrasonics are critical parameters.
- Aluminum wire should not be used.
- Maximum stage temperature is 175°C.